

Application Data Sheet

Application Information

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| Application Type:: | Regular |
| Subject Matter:: | Nationalization |
| Suggested Group Art Unit:: | N/A |
| CD-ROM or CD-R?:: | None |
| Sequence submission?:: | None |
| Computer Readable Form (CRF)?:: | No |
| Title:: | PHASE SHIFT MASK, FABRICATION METHOD THEREOF, AND FABRICATION METHOD OF SEMICONDUCTOR APPARATUS |
| Request for Early Publication?:: | No |
| Request for Non-Publication?:: | No |
| Small Entity?:: | No |
| Petition included?:: | No |
| Secrecy Order in Parent Appl.?:: | No |

Applicant Information

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|-------------------------------|---|
| Applicant Authority Type:: | Inventor |
| Primary Citizenship Country:: | Japan |
| Status:: | Full Capacity |
| Given Name:: | Minoru |
| Family Name:: | Sugawara |
| City of Residence:: | Kanagawa |
| Country of Residence:: | Japan |
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City of mailing address:: Tokyo
Country of mailing address:: Japan
Postal or Zip Code of mailing address:: 141-0001

Correspondence Information

Correspondence Customer Number:: 23353

Representative Information

Representative Customer Number:: 23353

Domestic Priority Information

| Application: | Continuity Type:: | Parent Application:: | Parent Filing Date:: |
|------------------|-------------------|----------------------|----------------------|
| This Application | National Stage of | PCT/JP03/08377 | 07/01/2003 |

Foreign Priority Information

| Country:: | Application number:: | Filing Date:: | Priority Claimed:: |
|-----------|----------------------|---------------|--------------------|
| Japan | P2002-193168 | 07/02/02 | Yes |
| Japan | P2002-200777 | 07/10/02 | Yes |

Assignee Information

Assignee name:: Sony Corporation
Street of mailing address:: 6-7-35 Kitashinagawa
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City of mailing address:: Tokyo
Country of mailing address:: Japan
Postal or Zip Code of mailing address:: 141-0001